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Vertical-Cavity Surface-Emitting Lasers XXIV

**Luke A. Graham
Chun Lei**
Editors

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Contents

v	<i>Authors</i>
vii	<i>Conference Committee</i>

SESSION 1 COMMERCIAL HIGH-POWER VCSELS

11300 02	Performance, manufacturability, and qualification advances of high-power VCSEL arrays at TriLumina Corporation (Invited Paper) [11300-1]
11300 05	Lasertel VCSEL development progress for automotive lidar [11300-4]
11300 06	Quality control optical characterization of NIR VCSEL based light sources for 3D imaging applications [11300-5]

SESSION 2 SINGLE-MODE APPLICATIONS

11300 09	Zero-order-free 2D beam pattern projecting on-chip lasers (Invited Paper) [11300-7]
11300 0B	Strain-controlled impurity-induced disordered apertures for high-power single-mode VCSELS [11300-9]
11300 0C	76X-nm VCSELS with wide tuning range designed for TDLAS [11300-10]

SESSION 3 HIGH-SPEED VCSELS: COMMERCIAL

11300 0E	20 and 40 Gbps data transmission with small VCSEL arrays [11300-12]
11300 0F	1×4 VCSEL arrays with uniform spectral and noise properties by using rotationally asymmetric oxide aperture for 400 Gbit/s applications [11300-13]
11300 0G	100Gb/s PAM4 oxide VCSEL development progress at Broadcom [11300-14]

SESSION 4 HIGH-SPEED VCSELS: EXPERIMENTAL

11300 0H	Quantum-dot oxide-confined 850-nm VCSELS with extreme temperature stability operating at 25 Gbit/s up to 180°C (Invited Paper) [11300-15]
----------	--

11300 OJ **Comparison of 850 nm VCSEL oxide aperture designs** [11300-17]

11300 OK **Oxidation stress induced birefringence in vertical cavity surface emitting lasers** [11300-18]

SESSION 5 VCSELS IN NOVEL MATERIAL SYSTEMS

11300 OM **Tunable room-temperature continuous-wave mid-infrared VCSELS (Invited Paper)** [11300-20]

SESSION 6 MEMS AND HIGH-CONTRAST GRATING DEVICES

11300 OR **MEMs-HCG VCSELS for emerging sensing and datacoms applications (Invited Paper)** [11300-26]

11300 OS **Widely tunable electrically pumped 1050nm MEMS-VCSELS for optical coherence tomography (Invited Paper)** [11300-27]

POSTER SESSION

11300 OW **894nm high orthogonal polarization suppression ratio vertical cavity surface emitting laser** [11300-30]

Authors

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Aoki, Takeshi, 0F
Bacchin, Gianluca, 02
Bandyopadhyay, Neelanjan, 0R
Boher, Pierre, 06
Borova, Iana, 0S
Bramham, Nate, 0S
Burgner, Christopher B., 0M, 0S
Cai, Xinle, 0G
Caliva, B., 05
Carter, John, 0S
Cazabat, Anthony, 0M, 0S
Chase, Chris, 0R
Chen, Hung Kai, 0R
Cheng, An-Nien, 0G
Cheng, Sam, 0R
Cherkashin, N., 0H
Chorchos, L., 0H, 0K
Chu, Jason, 0G
Chung, Michael, 02
Collomb-Patton, Véronique, 06
Dallesasse, John M., 0B
Dolfi, David W., 0G
Earls, Jeff, 02
Ellafi, Dalila, 0R
Fanning, Thomas R., 02
Feng, Zheng-Wen, 0G
Foresi, James, 02
Gębski, Marcin, 0J
Gerfers, F., 0K
Giovane, Laura M., 0G
Grabherr, M., 0C
Haghighi, Nasibeh, 0E, 0J
Hasnain, Ghulam, 0R
Hecht, U., 0K
Heermeier, Niels, 0J
Helms, Christopher J., 02
Hirose, Kazuyoshi, 09
Hsiao, Fu-Chen, 0B
Huang, Mike, 0R
Inoue, Daisuke, 0F
Ishizuka, Takashi, 0F
Jayaraman, V., 0M, 0S
Kalosha, V. P., 0H, 0K
Kamei, Hiroki, 09
Kan, Qiang, 0W
Kim, Sam Sangho, 0R
Koh, Gim-Hong, 0G
Kolasa, B., 0M
Kropp, J. -R., 0H, 0K
Kubota, Ryosuke, 0F
Kurosaka, Yoshitaka, 09
Kurth, P., 0K
Lascola, K., 0M
Ledentsov, N. N., 0H, 0K
Ledentsov, N., Jr., 0H, 0K
Lehman Harren, Ann, 0G
Leong, Nelvin, 0G
Leroux, Thierry, 06
Li, Ming, 0W
Lindblad, Chad, 0M, 0S
Lopez, Jacob, 02
Lott, James A., 0E, 0J
Maillard, J. M., 05
Makarov, O., 0H, 0K
Maynard, John, 02
Moser, Philip, 0E, 0J
Murty, M. V. Ramana, 0G
Nomoto, Yoshiro, 09
O'Brien, Thomas, Jr., 0B
Pikul, Kevin P., 0B
Podva, David, 02
Qiu, Pingping, 0W
Riaziat, Majid, 0J
Ruben, E., 05
Segal, S., 0M
Shchukin, V. A., 0H, 0K
Shoji, Hajime, 0F
Sridhara, Aadi, 0G
Su, Patrick, 0B
Sugiyama, Takahiro, 09
Takiguchi, Yu, 09
Taslim, Sumtro-Joyo, 0G
Thiagarajan, P., 05
Towner, F., 0M
Turkiewicz, J. P., 0H, 0K
Uenoyama, Soh, 09
Walker, R., 05
Wang, Jingyi, 0G
Wang, Qihua, 0W
Warren, Mial E., 02
West, L., 05
Wong, Ping-Show, 0J
Xie, F., 0M
Xie, Yiyang, 0W
Yanagisawa, Masaki, 0F
Yang, Lei, 02
Yang, Michael, 0R
Zorn, Martin, 0E

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Session Chairs

1 Commercial High-Power VCSELS

Luke A. Graham, Dallas Quantum Devices (United States)

- 2 Single-Mode Applications
James Guenter, Finisar Corporation (United States)
- 3 High-Speed VCSELs: Commercial
Chun Lei, Lumentum (United States)
- 4 High-Speed VCSELs: Experimental
Martin Grabherr, Priolas GmbH (Germany)
- 5 VCSELs in Novel Material Systems
Kent D. Choquette, University of Illinois (United States)
- 6 MEMs and High-Contrast Grating Devices
James A. Lott, Technische Universität Berlin (Germany)